



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : Confirmation No. 4981
Hiroshi TAKANASHI et al. : Docket No. 2000-1749
Serial No. 09/739,750 : Group Art Unit 1752
Filed December 20, 2000 : Examiner S. Lee

NEGATIVE-WORKING PHOTORESISTIVE
RESIN COMPOSITION AND PHOTORESISTIVE
RESIN PLATE USING THE SAME

RECEIVED
TO 1700 MAIL ROOM
NOV 22 2002
THE COMMISSIONER IS AUTHORIZED
TO CHARGE ANY DEFICIENCY IN THE
FEES FOR THIS PAPER TO DEPOSIT
ACCOUNT NO. 23-0975

PETITION FOR EXTENSION OF TIME

Assistant Commissioner for Patents,
Washington, DC 20231

Sir:

Petition hereby is made for a two month extension of time to respond to the communication of June 19, 2002.

The fee of \$400.00 is

(X) submitted herewith.
() to be charged to Deposit Account No. 23-0975. A duplicate copy of this Petition is enclosed.
() Small entity status of this application is established by the verified statement under 37 CFR 1.9 and 1.27 which
() is enclosed.
() has been previously submitted.

Respectfully submitted,

Hiroshi TAKANASHI et al.

By Matthew Jacob
Matthew Jacob
Registration No. 25,154
Attorney for Applicants

11/20/2002 JBALINAN 00000039 09739750

01 FC:1252

400.00 OP

MJ/jef
Washington, D.C. 20006-1021
Telephone (202) 721-8200
Facsimile (202) 721-8250
November 19, 2002